In the Specification:

Amend paragraph [0021] at page 6, as follows:

[0021] Layer (D) is a thin layer having layer thicknesses of from 1 to 100 nm, preferably from 1 to 50 nm, in particular from 5 to 20 nm. Layer (D) preferably comprises colored oxides, in particular metal oxides, including mixed oxides, sulfides, tellurides, selenides, lanthanides, phosphates, actinides and/or mixtures thereof.

Amend paragraph [0029] at page 8, as follows:

[0029] The coating may furthermore also take place in a fluidized-bed reactor by gasphase coating, e.g., by a CVD or PVD process, it being possible, for example, to use correspondingly the methods proposed in EP 0 045 851 and EP 0 106 235 for the preparation of pearlescent pigments.